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### **FILTER SYSTEM FOR A REACTOR SYSTEM**

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#### **Abstract**

A filter system of a reactor system may comprise a filter vessel comprising an outer wall; a filter plate disposed in the filter vessel; and a filter disposed on the filter plate. The filter plate may comprise a first plate face and a second plate face with a plate body spanning therebetween; a first plate hole disposed through the plate body spanning between the first plate face and the second plate face; and/or a plate hole rim protruding from the first plate surface. The plate hole rim may be disposed at or proximate a plate hole edge defining the first plate hole, and/or at least partially surrounding the first plate hole. The first filter may be disposed on the first plate face, and the first filter may engage with the plate hole rim such that the plate hole rim positions the first filter in a desired position.

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## Background/Summary

CROSS-REFERENCE TO RELATED APPLICATIONS [0001] This application is a divisional of, and claims priority to and the benefit of, U.S. patent application Ser. No. 17/136,764, filed Dec. 29, 2020 and entitled “FILTER SYSTEM FOR A REACTOR SYSTEM,” which is a nonprovisional of, and claims priority to and the benefit of, U.S. Provisional Patent Application No. 62/957,643, filed Jan. 6, 2020 and entitled “FILTER SYSTEM FOR A REACTOR SYSTEM,” all of which are hereby incorporated by reference herein.

### FIELD OF THE DISCLOSURE

[0002] The present disclosure relates generally to a semiconductor processing or reactor system and components comprised therein, and particularly to reactor system components that prevent contamination of other components.

### BACKGROUND OF THE DISCLOSURE

[0003] Reaction chambers may be used for depositing various material layers onto semiconductor substrates. A semiconductor may be placed on a susceptor inside a reaction chamber. Both the substrate and the susceptor may be heated to a desired substrate temperature set point. In an example substrate treatment process, one or more reactant gases may be passed over a heated substrate, causing the deposition of a thin film of material on the substrate surface. Throughout subsequent deposition, doping, lithography, etch, and other processes, these layers are made into integrated circuits.

[0004] For any given process, reactant gases and/or any byproduct gases may then be evacuated via a vacuum and/or purged from the reaction chamber. Reactant gases, and other gases or materials from the reaction chamber may be passed through a filter system, wherein the reactant gases or other materials (e.g., reaction products and/or byproducts) are trapped to prevent contamination of reactor system components downstream of the filter system. However, materials from the filter system may outgas under certain conditions, which may cause contamination of the reaction chamber or a substrate disposed therein.

### SUMMARY OF THE DISCLOSURE

[0005] This summary is provided to introduce a selection of concepts in a simplified form. These concepts are described in further detail in the detailed description of example embodiments of the disclosure below. This summary is not intended to identify key features or essential features of the claimed subject matter, nor is it intended to be used to limit the scope of the claimed subject matter.

[0006] In some embodiments, a filter system for a reactor system is provided. The filter system disclosed herein may allow collection of materials from a reaction chamber of the reactor system to reduce or prevent contamination of reactor system components downstream of the filter system. The filter system disclosed herein may also reduce or prevent possible contaminants from traveling to and contaminating the reaction chamber or a substrate disposed therein.

[0007] In various embodiments, a filter system for a reactor system may comprise a filter vessel comprising an outer wall; a filter plate disposed in the filter vessel; and a filter disposed on the filter plate. The filter plate may comprise a first plate face and a second plate face with a plate body spanning therebetween; a first plate hole disposed through the plate body spanning between the first plate face and the second plate face; and/or a plate hole rim protruding from the first plate surface. The plate hole rim may be disposed at or proximate a plate hole edge defining the first plate hole, and/or at least partially surrounding the first plate hole. The first filter may be disposed on the first plate face, and the first filter may engage with the plate hole rim such that the plate hole rim positions the first filter in a desired position. In various embodiments, the outer wall may

comprise at least one protrusion extending from the outer wall into an interior space of the filter vessel, which comprises the first filter.

[0008] In various embodiments, the first filter may comprise a filter bore through at least a portion of a length of the first filter, wherein the filter bore may be in fluid communication with the first plate hole. In various embodiments, the filter bore may be disposed through a filter first end, the filter first end being opposite a filter second end. In various embodiments, a shape of the plate hole rim may be complementary to a shape of the filter bore at the filter first end. The filter first end may be contacting the first plate face, such that the plate hole rim is disposed within the filter bore.

[0009] In various embodiments, the first filter may comprise a filter material surrounding the filter bore and spanning between the filter first end and the filter second end, wherein the filter first end may comprise a first filter end cap disposed thereon, and the filter second end may comprise a second filter end cap disposed thereon. The first filter end cap and/or the second filter end cap may be coupled to a support bar spanning between the first filter end cap and the second filter end cap, wherein the support bar may be monolithic or integral with the first filter end cap and/or the second filter end cap.

[0010] In various embodiments, the filter system may further comprise a baffle plate disposed on the filter second end, wherein the filter bore is disposed through the filter second end, and the baffle plate prevents or reduces a fluid from entering the filter bore through the filter second end. The baffle plate may facilitate the fluid passing through a side of the first filter between the filter first end and the filter second end. In various embodiments, the filter system may further comprise a plurality of filters, including the first filter, disposed in the filter vessel, wherein the baffle plate may comprise a baffle plate hole disposed through the baffle plate facilitating a portion of the fluid to flow between the plurality of filters. In various embodiments, the filter system may further comprise a plurality of plate holes, including the first plate hole, disposed through the plate body, each having a respective plate hole rim disposed at or proximate a respective plate hole edge for each of the plurality of plate holes. Each of the plurality of filters may comprise a respective filter bore, wherein each respective plate hole rim of the plurality of plate holes may be disposed within the respective filter bore of one of the plurality of filters.

[0011] In various embodiments, the filter vessel may comprise a vessel bottom surface comprising a vessel bottom hole disposed through the vessel bottom surface, wherein the filter plate may be disposed on the vessel bottom surface such that the first plate hole and the filter bore may be in fluid communication with the vessel bottom hole. In various embodiments, the vessel bottom surface may comprise a vessel bottom rim protruding from the vessel bottom surface and at least partially surrounding the vessel bottom hole, wherein the vessel bottom rim may engage with the filter plate to control a position of the filter plate.

[0012] In various embodiments, the filter plate may comprise a filter plate recess into the plate body through the second plate face, wherein a shape of the filter plate recess may be complementary to a shape of the vessel bottom rim. In various embodiments, the vessel bottom rim may be disposed in the filter plate recess. In various embodiments, the filter plate recess may at least partially surround the first plate hole.

[0013] In various embodiments, a method may comprise flowing a fluid from a reaction chamber into a filter system; flowing the fluid into a filter vessel and through a first filter comprised therein; collecting a contaminant comprised in the fluid in the filter material of the first filter as the fluid flows through the filter; and/or flowing the fluid through a first plate hole disposed through a filter plate. In various embodiments, the filter may comprise the filter material and a first filter bore disposed through the filter material, wherein the filter material may span a filter length between a filter first end and a filter second end. The first filter bore may be disposed at least through the filter first end, and the fluid may flow through the filter material and then through the first filter bore. In various embodiments, the filter plate may comprise a first plate face and a second plate face with a plate body spanning therebetween, and a plate hole rim protruding from the first plate surface that

engages with the first filter to maintain the first filter in a desired position. The first filter bore and the first plate hole may be in fluid communication through the filter first end. The filter plate may be disposed on a vessel bottom surface of the filter vessel.

[0014] In various embodiments, the method may further comprise flowing the fluid through a vessel bottom hole disposed through the vessel bottom surface, wherein the first plate hole may be in fluid communication with the vessel bottom hole. In various embodiments, the method may further comprise collecting a portion of the contaminant on an interior surface of an outer wall of the filter vessel, wherein the interior surface may comprise at least one protrusion extending into an interior space of the filter vessel.

[0015] For the purpose of summarizing the disclosure and the advantages achieved over the prior art, certain objects and advantages of the disclosure have been described herein above. Of course, it is to be understood that not necessarily all such objects or advantages may be achieved in accordance with any particular embodiment of the disclosure. Thus, for example, those skilled in the art will recognize that the embodiments disclosed herein may be carried out in a manner that achieves or optimizes one advantage or group of advantages as taught or suggested herein without necessarily achieving other objects or advantages as may be taught or suggested herein.

[0016] All of these embodiments are intended to be within the scope of the disclosure. These and other embodiments will become readily apparent to those skilled in the art from the following detailed description of certain embodiments having reference to the attached figures, the disclosure not being limited to any particular embodiment(s) discussed.

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## Description

### BRIEF DESCRIPTION OF THE DRAWING FIGURES

[0017] While the specification concludes with claims particularly pointing out and distinctly claiming what are regarded as embodiments of the disclosure, the advantages of embodiments of the disclosure may be more readily ascertained from the description of certain examples of the embodiments of the disclosure when read in conjunction with the accompanying drawings.

Elements with the like element numbering throughout the figures are intended to be the same.

[0018] FIG. 1 illustrates a schematic diagram of an exemplary reactor system, in accordance with various embodiments;

[0019] FIG. 2 illustrates an exploded view of an exemplary filter system, in accordance with various embodiments;

[0020] FIGS. 3A and 3B illustrate perspective views of an exemplary filter comprised in a filter system, in accordance with various embodiments;

[0021] FIG. 4A illustrates a top perspective view of an exemplary filter plate comprised in a filter system, in accordance with various embodiments;

[0022] FIG. 4B illustrates a cross-sectional view of the filter plate of FIG. 4A along the axis X-Y shown in FIG. 4A, in accordance with various embodiments;

[0023] FIG. 4C illustrates a bottom perspective view of an exemplary filter plate comprised in a filter system, in accordance with various embodiments;

[0024] FIG. 5 illustrates an exemplary top baffle disposed on filters of a filter system, in accordance with various embodiments;

[0025] FIG. 6 illustrates a perspective view of an exemplary filter vessel of a filter system, in accordance with various embodiments;

[0026] FIGS. 7A-7C illustrate exemplary filter vessels having various configurations, in accordance with various embodiments;

[0027] FIG. 8 illustrates a cross section of an exemplary filter vessel comprising a top baffle, filters, and a filter plate, and fluid flow through the filter vessel, in accordance with various

embodiments; and

[0028] FIG. 9 illustrates a method of flowing fluid through a filter system of a reactor system, in accordance with various embodiments.

#### DETAILED DESCRIPTION

[0029] Although certain embodiments and examples are disclosed below, it will be understood by those in the art that the disclosure extends beyond the specifically disclosed embodiments and/or uses of the disclosure and obvious modifications and equivalents thereof. Thus, it is intended that the scope of the disclosure should not be limited by the particular embodiments described herein.

[0030] The illustrations presented herein are not meant to be actual views of any particular material, apparatus, structure, or device, but are merely representations that are used to describe embodiments of the disclosure.

[0031] As used herein, the term “substrate” may refer to any underlying material or materials that may be used, or upon which, a device, a circuit, or a film may be formed.

[0032] As used herein, the term “atomic layer deposition” (ALD) may refer to a vapor deposition process in which deposition cycles, preferably a plurality of consecutive deposition cycles, are conducted in a process chamber. Typically, during each cycle the precursor is chemisorbed to a deposition surface (e.g., a substrate surface or a previously deposited underlying surface such as material from a previous ALD cycle), forming a monolayer or sub-monolayer that does not readily react with additional precursor (i.e., a self-limiting reaction). Thereafter, if necessary, a reactant (e.g., another precursor or reaction gas) may subsequently be introduced into the process chamber for use in converting the chemisorbed precursor to the desired material on the deposition surface. Typically, this reactant is capable of further reaction with the precursor. Further, purging steps may also be utilized during each cycle to remove excess precursor from the process chamber and/or remove excess reactant and/or reaction byproducts from the process chamber after conversion of the chemisorbed precursor. Further, the term “atomic layer deposition,” as used herein, is also meant to include processes designated by related terms such as, “chemical vapor atomic layer deposition”, “atomic layer epitaxy” (ALE), molecular beam epitaxy (MBE), gas source MBE, or organometallic MBE, and chemical beam epitaxy when performed with alternating pulses of precursor composition(s), reactive gas, and purge (e.g., inert carrier) gas.

[0033] As used herein, the term “chemical vapor deposition” (CVD) may refer to any process wherein a substrate is exposed to one or more volatile precursors, which react and/or decompose on a substrate surface to produce a desired deposition.

[0034] As used herein, the term “film” and “thin film” may refer to any continuous or non-continuous structures and material deposited by the methods disclosed herein. For example, “film” and “thin film” could include 2D materials, nanorods, nanotubes, or nanoparticles or even partial or full molecular layers or partial or full atomic layers or clusters of atoms and/or molecules. “Film” and “thin film” may comprise material or a layer with pinholes, but still be at least partially continuous.

[0035] As used herein, the term “contaminant” may refer to any unwanted material disposed within the reaction chamber that may affect the purity of a substrate disposed in the reaction chamber, or any unwanted material in any component of a reaction system. The term “contaminant” may refer to, but is not limited to, unwanted deposits, metal and non-metal particles, impurities, and waste products, disposed within the reaction chamber or other components of the reactor system.

[0036] Reactor systems used for ALD, CVD, and/or the like, may be used for a variety of applications, including depositing and etching materials on a substrate surface. In various embodiments, a reactor system 50 may comprise a reaction chamber 4, a susceptor 6 to hold a substrate 30 during processing, a fluid distribution system 8 (e.g., a showerhead) to distribute one or more reactants to a surface of substrate 30, one or more reactant sources 10, 12, and/or a carrier and/or purge gas source 14, fluidly coupled to reaction chamber 4 via lines 16-20, and valves or controllers 22-26. Reactant gases or other materials from reactant sources 10, 12 may be applied to

substrate **30** in reaction chamber **4**. A purge gas from purge gas source **14** may be flowed to and through reaction chamber **4** to remove any excess reactant or other undesired materials from reaction chamber **4**. System **50** may also comprise a vacuum source **28** fluidly coupled to the reaction chamber **4**, which may be configured to suck reactants, a purge gas, or other materials out of reaction chamber **4**. System **50** may comprise a filter system **40** disposed between reaction chamber **4** and vacuum source **28** to trap (i.e., accumulate) materials (e.g., contaminants) coming from reaction chamber **4**, reducing or preventing contamination of reactor system **50** components downstream of filter system **40**.

[0037] With reference to FIG. 2, a filter system **100** (an exploded view thereof) is illustrated, in accordance with various embodiments. Filter system **100** can be the same as or similar to filter system **40**. In various embodiments, filter system **100** may comprise an outer filter housing **103**, which may comprise multiple components (e.g., upper outer housing **103A** and lower outer housing **103B**). In various embodiments, upper outer housing **103A** and lower outer housing **103B** may couple to enclose other components of filter system **100**. Upper outer housing **103A** may comprise a fluid inlet **101A**, through which the interior of outer filter housing **103** may be fluidly coupled to a reaction chamber (e.g., reaction chamber **4**). Gases and other material may flow from the reaction chamber into filter system **100** through fluid inlet **101A**, and may exit filter system **100** through fluid outlet **101B**.

[0038] In various embodiments, filter system **100** may comprise a filter vessel **130**. Filter vessel **130** may be disposed in one or more components of outer filter housing **103**. For example, filter vessel **130** may be disposed in lower outer housing **103B** and/or upper outer housing **103A**. In various embodiments, upper outer housing **103A** may couple with filter vessel **130**, enclosing and/or sealing a filter vessel interior space of filter vessel **130**. Accordingly, filter vessel **130** may comprise a shape (e.g., an outer shape) complementary to a shape of the interior of upper outer housing **103A** and/or lower outer housing **103B**.

[0039] With additional reference to FIG. 6, a filter vessel **600** (an example of filter vessel **130** in FIG. 2) may comprise a filter vessel outer wall **610** having a wall interior surface **615**. Wall interior surface **615** may define and/or enclose an interior space of filter vessel **600**. In various embodiments, outer wall **610** may engage and/or couple with an upper outer housing (e.g., upper outer housing **103A**) to enclose and/or seal the interior space of filter vessel **600**.

[0040] In various embodiments, the lower bound of the interior space of filter vessel **600** may be a vessel bottom spanning between the outer wall **610** or portions thereof. The vessel bottom may comprise a vessel bottom surface **605**. Vessel bottom surface may comprise one or more vessel bottom holes **620** disposed through the vessel bottom. The interior space of filter vessel **600** may be in fluid communication with fluid outlet **101B** via the vessel bottom holes **620**. In various embodiments, a vessel bottom hole **620** may be defined by a vessel bottom hole edge. A vessel bottom hole **620** may comprise any suitable shape.

[0041] In various embodiments, vessel bottom surface **605** may comprise a vessel bottom rim **630** protruding from vessel bottom surface **605**. Vessel bottom rim **630** may be disposed at or proximate a respective vessel bottom hole edge. In various embodiments, each vessel bottom hole **620** may comprise a vessel bottom rim **630** disposed at or proximate the respective vessel bottom hole edge. Vessel bottom rim **630** may at least partially surround a respective vessel bottom hole **620**, forming a shape of the vessel bottom rim **630**.

[0042] In various embodiments, filter vessel **600** may comprise a coupling rod **650** protruding from vessel bottom surface **605**. Coupling rod **650** may comprise any suitable shape, length, and/or cross-sectional shape. In various embodiments, coupling rod **650** may protrude from vessel bottom surface **605** above a plane defined by an upper edge of vessel outer wall **610** (wherein a height of vessel outer wall **610** spans between the vessel bottom surface and the vessel outer wall **610** upper edge). Coupling rod **650** may be configured to engage and/or couple with other components of filter system **100**. In various embodiments, at least a portion of coupling rod **650** may comprise

threading.

[0043] With reference again to FIG. 2, in various embodiments, filter system **100** may comprise a filter plate **200**. Filter plate **200** may be disposed in filter vessel **130**, for example, adjacent to and/or coupled to the filter vessel bottom surface (e.g., filter vessel bottom surface **605** of filter vessel **600** in FIG. 6).

[0044] With additional reference to FIGS. 4A-4C, a filter plate **400** (an example of filter plate **200** in FIG. 2) may comprise a first plate face **405**, a second plate face **410**, and a plate body **415** spanning between first plate face **405** and second plate face **410**. First plate face **405** and/or second plate face **410** may comprise any suitable configuration, such as being substantially flat, concave, or convex. In various embodiments, filter plate **400** may comprise at least one plate hole **420** disposed through first plate face **405**, second plate face **410**, and plate body **415** spanning therebetween. In various embodiments, a plate hole **420** may be defined by a plate hole edge **422**. A plate hole **420** may comprise any suitable shape.

[0045] In various embodiments, first plate face **405** may comprise a plate hole rim **430** protruding from first plate face **405**. Plate hole rim **430** may be disposed at or proximate a respective plate hole edge **422**. In various embodiments, each plate hole **420** may comprise a plate hole rim **430** disposed at or proximate the respective plate hole edge **422**. Plate hole rim **430** may at least partially surround a respective plate hole **420**, forming a shape of the plate hole rim **430**. In various embodiments, a plate hole rim may be any protrusion from first plate face **405** (e.g., that is used at least to dispose a filter in a desired position on first plate face **405**).

[0046] In various embodiments, filter plate **400** may comprise a coupling hole **455**. Coupling hole **455** may comprise a shape that is complementary to the cross-sectional shape of coupling rod **650** of filter vessel **600** in FIG. 6. Accordingly, coupling rod **650** may be disposed through coupling hole **455**, such that coupling rod **650** maintains a desired position of filter plate **400** within the interior space of filter vessel **600**.

[0047] With combined reference to FIGS. 4A-C and 6, in various embodiments, filter plate **400** may be disposed adjacent to bottom surface **605** of filter vessel **600**. Second plate face **410** may be in contact with bottom surface **605** of filter vessel **600**. The shape of filter plate **400** may be complementary to a cross-sectional shape of the interior space of filter vessel **600**, such that filter plate **400** may be disposed therein. Accordingly, an outer edge of filter plate **400** may be disposed adjacent to, and/or in contact with, outer wall interior surface **615** of filter vessel outer wall **610**. Filter plate **400** may fit within the interior space of filter vessel **600** such that little or no fluid may pass between the outer edge of filter plate **400** and outer wall interior surface **615** of filter vessel outer wall **610**, and/or between second plate face **410** and filter vessel bottom surface **605**.

[0048] In various embodiments, vessel bottom rim **630** may engage and/or couple with filter plate **400** to maintain filter plate **400** in a desired position on or relative to filter vessel bottom surface **605** and/or a vessel bottom hole **620**. In various embodiments, vessel bottom rim **630** may comprise a shape that is complementary to the shape of plate hole **420**, such that each vessel bottom rim **630** may be disposed in a respective vessel bottom hole **620**. For example, each of the four vessel bottom rims **630** in FIG. 6 may be disposed within a respective one of the four plate holes **420**. In such embodiments, each vessel bottom rim **630** may be disposed proximate or against the plate hole edge **422** of the respective plate hole **420**.

[0049] In various embodiments, filter plate **400** may comprise a filter plate recess **425** disposed into plate body **415** through second plate face **410**. A filter plate recess **425** may not be disposed completely through filter plate **400**, but only partially into plate body **415** through second plate face **410** toward first plate face **405**. A filter plate recess **425** may be disposed on filter plate **400** proximate and/or adjacent to a plate hole **420**. In various embodiments, a filter plate recess **425** may be disposed at least partially surrounding a respective plate hole **420**. For example, as shown in FIG. 4C, there may be a plate recess **425** disposed around each respective plate hole **420**.

[0050] Each filter plate recess **425** may comprise any suitable shape. In various embodiments, a

filter plate recess **425** may comprise a shape that is complementary to the shape of a vessel bottom rim **630**, such that the vessel bottom rim **630** may be disposed in a respective filter plate recess **425**. In such embodiments, a vessel bottom rim **630** may engage and/or couple with a respective filter plate recess **425**. For example, a vessel bottom hole **620** may be larger than a plate hole **420**. A vessel bottom rim **630** at least partially surrounding a vessel bottom hole **620** may be disposed in a respective filter plate recess **425** at least partially surrounding the respective plate hole **420**. In various embodiments, a vessel bottom rim **630** may be disposed adjacent to, and/or in contact with, an outer edge of a respective filter plate recess **425**, such that there is little or no space between the vessel bottom rim **630** and the outer edge of the respective filter plate recess **425**. The engaging and/or coupling of a vessel bottom rim **630** with a respective filter plate recess **425** may be configured to maintain filter plate **400** in a desired position on or relative to filter vessel bottom surface **605** and/or a vessel bottom hole **620**.

[0051] Filter plate **400** engaging and/or coupling to vessel bottom surface **605** via a vessel bottom rim **630** may align each plate hole **420** with a respective vessel bottom hole **620** so fluid may travel therethrough. Relatedly, in various embodiments, the filter plate recesses **425** disposed in filter plate **400** and/or the vessel bottom rims **630** provide a self-aligning quality to filter plate **400** and its disposal into filter vessel **600** and against filter vessel bottom surface **605**. That is, the vessel bottom rim(s) **630** of the filter vessel may only engage a respective and/or complementary portion of filter plate **400** (e.g., plate holes **420** and/or filter plate recesses **425**) in response to filter plate **400** being correctly positioned within filter vessel **600**.

[0052] With reference back to FIG. 2, filter system **100** may comprise one or more filters **120**. Filters **120** may be disposed on filter plate **200** and within filter vessel **130**.

[0053] With additional reference to FIGS. 3A and 3B, a filter **300** (an example of filter **120** in FIG. 2) may comprise a filter first end **310**, a filter second end **320**, and a filter body therebetween. The filter body **340** may comprise a filter material configured to accumulate or trap materials flowing through the filter material. The filter material may comprise any suitable material, such as wire mesh and/or any material comprising a geometry providing surface area (e.g., a high surface area to volume ratio) upon which contaminants may deposit (e.g., materials traveling from reaction chamber **4**). Filter body **340** may comprise a filter wall **345** surrounding the filter material. Filter wall **345** may comprise any suitable configuration, such as a mesh, a screen, or any other permeable or perforated material (i.e., a material and/or configuration through which fluids may flow).

[0054] In various embodiments, filter **300** may comprise an end cap on one or more of filter first end **310** and filter second end **320**. For example, filter first end **310** may comprise a first filter end cap **312**, and filter second end **320** may comprise a second filter end cap **322**. The end caps may be disposed over the ends of filter wall **345**. The end caps may be configured such that fluids may not pass therethrough.

[0055] In various embodiments, filter **300** may comprise at least one support bar **330** spanning between first filter end cap **312** and second filter end cap **322**. Support bar **330** may provide structure to filter body **340**, the filter material, and/or filter wall **345**. Support bar **330** may be coupled to first filter end cap **312** and/or second filter end cap **322**. In various embodiments, support bar **330** may be integral with, and/or monolithic with, first filter end cap **312** and/or second filter end cap **322**, such that there are no seams between such components.

[0056] In various embodiments, no adhesive or other coupling material may be used to couple a support bar **330** to first filter end cap **312** and/or second filter end cap **322**. The absence of an adhesive, epoxy, or other coupling material mitigates the risk of such a coupling material outgassing and traveling to the reaction chamber, acting as a contaminant therein. Additionally, without such a coupling material, filter **300** may not be susceptible to degradation at elevated temperatures, for example, greater than 120° C. Therefore, a filter system comprising filter **300** (e.g., filter system **100** in FIG. 2) may be moved closer to a reaction chamber of a reactor system



(e.g., reaction chamber **4** of reactor system **50** in FIG. **1**) than a filter system comprising a filter with a coupling material. Accordingly, a reactor system having a filter system comprising filter **300** may be more compact and/or have more feasible configurations and special arrangements.

[0057] In various embodiments, filter **300** may comprise a filter bore **350** disposed in and/or surrounded by filter body **340** and/or the filter material. A portion of filter wall (or the same/similar material) may surround filter bore **350**. Filter bore **350** may span at least a portion of a filter length of filter **300** between filter first end **310** and filter second end **320**. In various embodiments, filter bore **350** may span through filter first end **310** and/or filter second end **320**. In various embodiments, filter bore **350** may span through first filter end cap **312** and/or second filter end cap **322**. In various embodiments, filter bore **350** may span the entire length of filter **300**, including through filter first end **310** and filter second end **320**, and if filter **300** comprises end caps, through first filter end cap **312** and second filter end cap **322**.

[0058] In various embodiments, a portion of filter bore **350** disposed through filter first end **310** and/or first filter end cap **312** may be configured to engage with and/or couple to a filter plate (e.g., filter plate **400** in FIGS. **4A-4C**). With additional reference to FIGS. **4A-4C** and **6**, filter bore **350** may be configured to be in fluid communication with a respective plate hole **420** and bottom surface hole **620d** of filter vessel **600**. Filter bore **350** disposed through filter first end **310** (and/or first filter end cap **312**) may comprise a cross-sectional shape, at least a portion of which is complementary with the shape of a plate hole rim **430**. Accordingly, plate hole rim **430** may engage with and/or couple to the filter bore **350** portion through filter first end **310** (and/or first filter end cap **312**). For example, a plate hole rim **430**, associated with a respective plate hole **420**, may be disposed within the portion of filter bore **350** disposed through filter first end **310** (and/or first filter end cap **312**), such that filter bore **350** is in fluid communication with the respective plate hole **420**. In various embodiments, a plate hole rim **430** may be disposed adjacent to, and/or in contact with, a filter bore outer edge **352**, such that there is little or no space between the plate hole rim **430** and filter bore outer edge **352**.

[0059] The complementary shape of filter bore **350** proximate filter first end **310** to the shape of plate hole rim **430** allows for easy alignment and placement of a filter **300** on filter plate **400** in filter vessel **600**. That is, plate hole rim **430** of a plate hole **420** may only engage the filter bore **350** of a respective filter **300** in response to filter **300** being correctly positioned on filter plate **400** within filter vessel **600**, therefore, facilitating alignment of a respective filter bore **350**, plate hole **420**, and/or vessel bottom hole **620**.

[0060] In various embodiments, a filter system (e.g., filter system **100**) of a reactor system may comprise multiple filters **300**. For example, as depicted and/or indicated in FIGS. **3A**, **3B**, **4A-4C**, **5**, and **6**, a filter system may comprise four filters **300** in filter vessel **600**. The four plate holes **420** on filter plate **400** may align with the four vessel bottom holes **620**, as described herein. Similarly, the filter bore **350** of each of four filters **300** may align with a respective four plate holes **420**, such that each vessel bottom hole **620** is aligned and in fluid communication with a respective plate hole **420** and filter bore **350**. Four filters **300** disposed on filter plate **400** and in filter vessel **600** may be comprised in the configurations depicted in FIG. **5** in FIGS. **7A-7C** (which depict top perspective views of filters **120** from FIG. **2**). A filter system and/or filter vessel may comprise any suitable number of filters in any suitable arrangement.

[0061] In various embodiments, with reference back to FIG. **2**, filter system **100** may comprise a baffle plate **110**. With additional reference to FIGS. **3A**, **3B**, **5**, and **6**, a baffle plate **500** (an example of baffle plate **110** in FIG. **2**) may be disposed on filters **300** (discussed in relation to FIGS. **3A,B**). In various embodiments, baffle plate **500** may cause fluid flow entering the interior space of filter vessel **600** to take a certain path (e.g., a path that will maximize fluid flow through filters **300**, and/or allow maximum removal of contaminants from the fluid flow by the filter system and its components). Baffle plate **500** may reduce or prevent fluid flow from traveling around or through filter second end **320**, second filter end cap **322**, and/or a portion of filter bore

**350** disposed through filter second end **320** and/or second filter end cap **322**. That is, baffle plate **500** may form at least a partial seal between baffle plate **500** and filter second end **320** and/or second filter end cap **322**. Baffle plate **500** may be configured to cause at least a portion of fluid flow within a filter vessel to flow around baffle plate edge **520** toward and through filters **300** and portions thereof more proximate to wall interior surface **615** than other portions of filters **300**. In various embodiments, baffle plate **500** may comprise one or more baffle holes **530** proximate a center of baffle plate **500**. Baffle holes **530** may be configured to cause fluid flow to travel therethrough, toward and through filters **300** and portions of filters **300** more proximate a center of the interior space of filter vessel **600** than other portions of filters **300** (e.g., between filters **300** disposed under baffle plate **500**). Baffle holes on a baffle plate may be in any suitable position or any suitable configuration to achieve desired fluid flow toward and through filters.

[0062] In various embodiments, coupling system **105** shown in FIG. 2 may couple baffle plate **110** and/or filter plate **200** to filter vessel **130**, for example, by engaging with and/or coupling to coupling rod **132** (an example of coupling rod **650** in FIG. 6). For example, at least one component of coupling system **105** may engage with the threading on coupling rod **132**.

[0063] In various embodiments, the components of filter system **100** may be clamped and/or sealed together via sealing ring **142** and/or clamping ring **144**. A sealing ring **142** may be disposed between filter vessel **130** and upper outer housing **103A**, between upper outer housing **103A** and lower outer housing **103B**, between filter vessel **130** and lower outer housing **103B**, and/or in any other suitable location. Sealing ring **142** may be comprised of any suitable material, such as rubber, a polymeric material, and/or the like to at least partially seal the filter system components around the interior space of filter vessel **130**. Clamping ring **144** may be disposed around upper outer housing **103A** and/or lower outer housing **103B**, and may be configured to be tightened to hold components of filter system **100** together.

[0064] FIG. 9 illustrates a method **900** of flowing fluid through a filter system in a reaction system, in accordance with various embodiments. With additional reference to FIGS. 3A-3B, 4A-4C, 5, 6, and 8, a fluid may flow from a reaction chamber (e.g., reaction chamber **4** in FIG. 1) to a filter system (e.g., filter system **100** in FIG. 2, or filter system **800** in FIG. 8) (step **902**). Filter system **800** in FIG. 8 may comprise a fluid inlet **801A** and a fluid outlet **801B** of an outer filter housing (similar to fluid inlet **101A** and fluid outlet **101B** of outer filter housing **103** in FIG. 2). Fluid **880** may flow into filter system **800** through fluid inlet **801A**. Fluid **880** may comprise materials which the filter system is configured to remove from fluid **880** (e.g., contaminants).

[0065] In various embodiments, the fluid may flow into a filter vessel (e.g., filter vessel **600** or filter vessel **130** in FIG. 2), and through a filter **820** (similar to filter **300** or filter **120** of FIG. 2) (step **904**). In various embodiments, the filter vessel may be coupled to and/or a part of the outer filter housing of the filter system. In various embodiments, an upper outer housing (e.g., upper outer housing **103A** of FIG. 2) may couple to and/or engage with the filter vessel to enclose an interior space of the filter vessel and/or outer filter housing, which houses and encloses the filter(s).

[0066] After entry to the filter vessel, fluid **880** may contact baffle plate **810** (an example of baffle plate **500** and baffle plate **110** in FIG. 2). Baffle plate **810** may direct at least a portion of fluid **880** (e.g., fluid **880A**) around an outer edge **812** (an example of outer edge **520** of baffle plate **500**) to contact a wall interior surface **805** (an example of wall interior surface **615** of filter vessel **600**) and/or to contact and/or pass through portions of filters **820** more proximate wall interior surface **805** than other portions of filters **820** (e.g., portions of filters **820** facing one another). In various embodiments, baffle plate **810** may direct at least a portion of fluid **880** (e.g., fluid **880B**) through baffle holes **814** (examples of baffle holes **530**) to contact and/or pass through portions of filters **820** more proximate a center of the interior space of the filter vessel, or more proximate other filters **820**, than other portions of filters **820** (e.g., portions of filters **820** facing wall interior surface **805**).

[0067] Fluid **880A** and **880B** may pass through the filter material **828** of filters **820** into the filter

bore **826** (an example of filter bore **350**) in each filter **820**. The filter material may collect contaminants from fluid **880** (step **906**) as fluid **880** flows through the filter material. As an additional part of the collecting a contaminant from fluid **880** of step **906**, contaminants may be deposited on surfaces within the filter system, such as on wall interior surface **805**, the filter wall (e.g., filter wall **345**), a filter end cap(s), and/or any other component of filter **820** or filter system **800**. According, with reference to FIGS. 7A-7C, in various embodiments, the filter vessel outer wall of the illustrated filter vessels may comprise one or more protrusions extending out from the wall interior surface into the internal space of the filter vessel (i.e., from the wall interior surface toward the filter(s) disposed in the internal space of the filter vessel). Such protrusions may comprise any suitable shape, and may provide additional surface area upon which contaminants may deposit or collect.

[0068] A filter vessel and/or filter system may comprise any suitable number of protrusions in any suitable shape, arrangement, and/or configuration. For example, in FIG. 7A, a filter vessel **700A** may comprise a filter vessel outer wall **710A** (an example of filter vessel outer wall **610**) surrounding a filter vessel internal space, in which filters **120** may be disposed (top perspective views of filters **120** in FIG. 2). Filter vessel outer wall **710A** may comprise one or more protrusions **745A** extending from wall interior surface **715A** into the vessel internal space. Protrusions **745A** may comprise a substantially rectangular shape. As another example, in FIG. 7B, a filter vessel **700B** may comprise a filter vessel outer wall **710B** (an example of filter vessel outer wall **610**) surrounding a filter vessel internal space, in which filters **120** may be disposed (top perspective views of filters **120** in FIG. 2). Filter vessel outer wall **710B** may comprise one or more protrusions **745B** extending from wall interior surface **715B** into the vessel internal space. Protrusions **745B** may comprise a substantially triangular shape. As yet another example, in FIG. 7C, filter vessel **700C** may comprise filter vessel outer wall **710B**, which may comprise one or more protrusions **745B** extending from wall interior surface **715B** into the vessel internal space. In various embodiments, the bottom surface of the vessel internal space (e.g., first plate face **405** of filter plate **400** in FIGS. 4A-4C) may comprise protrusions **735C** extending from the bottom surface into the vessel internal space. Protrusions **735C** may be alternative or in addition to protrusions **745B** from wall interior surface **715B**. Protrusions **745A,B** and **735C** may provide additional surface area upon which contaminants in fluid flowing through the respective filter vessel and/or system may deposit, thus removing such contaminants from the fluid.

[0069] In various embodiments, continuing with method **900**, fluid **880** may flow through filter bores **826**, including through filter first ends **824** of filters **820**, and through filter plate **840** (an example of filter plate **400** or filter plate **200** in FIG. 2) (step **908**). Fluid **880** flowing through filter plate **840** may comprise minimal or no contaminants. Filter plate **840** may comprise plate holes **842** disposed therethrough between a first plate face (e.g., first plate face **405**) and a second plate face (e.g., second plate face **410**) of filter plate **840**. Filter plate **840** may further comprise plate hole rim **844** (an example of plate hole rim **430** of filter plate **400**) engaged with and/or coupled to filter **820** and/or filter bore **826**, for example, as described herein with relation to filter plate **400** and filter **300**. Accordingly, filter bores **826** may be aligned and/or in fluid communication with plate holes **842**. Therefore, fluid **880** may flow from filter bore **826** through filter plate **840** via plate holes **842**. Filter plate **840** may further comprise filter plate recesses **846** disposed into filter plate **840** through the second plate face.

[0070] In various embodiments, fluid **880** may flow through filter vessel bottom surface **860** (an example of filter vessel bottom surface **605** of filter vessel **600**) and the filter vessel bottom (step **910**). Filter vessel bottom surface **860** may comprise vessel bottom holes **862** disposed through the vessel bottom. Filter vessel bottom surface **860** may further comprise vessel bottom rim **864** (an example of vessel bottom rim **630** of filter vessel **600**) engaged with and/or coupled to filter plate **840**, for example, engaging and/or coupling with plate holes **842** and/or plate recesses **846**, and/or as described herein with relation to filter plate **400** and filter vessel **600**. Accordingly, plate holes

**842** may be aligned and/or in fluid communication with vessel bottom holes **862**. Therefore, fluid **880** may flow from filter bore **826** through filter plate **840** via plate holes **842**, and through filter vessel bottom surface **860** via vessel bottom holes **862**.

[0071] Subsequently, fluid **880** may flow through fluid outlet **801B**, and out of filter system **800**.

[0072] The components of the systems discussed herein may be comprised of any suitable material such as metal or metal alloy (e.g., steel, aluminum, aluminum alloy, or the like).

[0073] Although exemplary embodiments of the present disclosure are set forth herein, it should be appreciated that the disclosure is not so limited. For example, although reactor and filter systems are described in connection with various specific configurations, the disclosure is not necessarily limited to these examples. Various modifications, variations, and enhancements of the system and method set forth herein may be made without departing from the spirit and scope of the present disclosure.

[0074] The subject matter of the present disclosure includes all novel and nonobvious combinations and subcombinations of the various systems, components, and configurations, and other features, functions, acts, and/or properties disclosed herein, as well as any and all equivalents thereof.

## Claims

1. A reactor system, comprising: a reaction chamber; and a filter system in fluid communication with the reaction chamber, the filter system comprising: a filter vessel comprising an outer wall at least partially defining an interior space; a filter plate disposed in the filter vessel, the filter plate comprising: a first plate face and a second plate face with a plate body spanning therebetween; a first plate hole disposed through the plate body spanning between the first plate face and the second plate face; and a plate hole rim protruding from the first plate surface and at least partially surrounding the first plate hole; a plurality of filters disposed on the first plate face, wherein a first filter of the plurality of filters engages with the plate hole rim such that the plate hole rim positions the first filter in a desired position, wherein the first filter comprises and spans between a first filter end and a second filter end; and a baffle plate disposed on the filter second end, wherein the baffle plate facilitates the fluid passing through a portion of the plurality of filters more proximate the outer wall of the filter vessel, wherein the baffle plate comprises a baffle plate hole disposed through the baffle plate, facilitating a portion of the fluid to flow through the baffle plate, between at least two of the plurality of filters, and through a portion of the plurality of filters more proximate a center of the interior space of the filter vessel.

2. The reactor system of claim 1, wherein the first filter comprises a filter bore disposed through the filter first end and spanning at least partially between the filter first end and the filter second end, wherein the filter bore is in fluid communication with the first plate hole.

3. The reactor system of claim 2, wherein a shape of the plate hole rim is complementary to at least a portion of a shape of the filter bore at the filter first end, wherein the plate hole rim is disposed within the filter bore.

4. The reactor system of claim 1, wherein the filter first end comprises a first filter end cap disposed thereon, and the filter second end comprises a second filter end cap disposed thereon.

5. The reactor system of claim 4, wherein the first filter end cap and the second filter end cap are coupled to a support bar spanning between the first filter end cap and the second filter end cap.

6. The reactor system of claim 1, further comprising a plurality of plate holes, including the first plate hole, disposed through the plate body, each having a respective plate hole rim disposed at least partially around a respective plate hole for each of the plurality of plate holes.

7. The reactor system of claim 6, wherein each of the plurality of filters comprises a respective filter bore, wherein each respective plate hole rim of the plurality of plate holes is disposed within the respective filter bore of one of the plurality of filters.

8. The reactor system of claim 2, wherein the filter vessel comprises a vessel bottom surface

comprising a vessel bottom hole disposed through the vessel bottom surface, wherein the filter plate is disposed on the vessel bottom surface such that the first plate hole and the filter bore are in fluid communication with the vessel bottom hole.

**9.** The reactor system of claim 8, wherein the vessel bottom surface comprises a vessel bottom rim protruding from the vessel bottom surface and at least partially surrounding the vessel bottom hole, wherein the vessel bottom rim engages with the filter plate to control a position of the filter plate.

**10.** The reactor system of claim 9, wherein the filter plate comprises a filter plate recess into the plate body through the second plate face, wherein a shape of the filter plate recess is complementary to a shape of the vessel bottom rim, wherein the vessel bottom rim is disposed in the filter plate recess.

**11.** The reactor system of claim 1, wherein the outer wall of the filter vessel comprises at least one protrusion extending from the outer wall into the interior space of the filter vessel between at least two of the plurality of filters.

**12.** A reactor system, comprising: a reaction chamber; and a filter system in fluid communication with the reaction chamber, the filter system comprising: a filter vessel comprising an outer wall, an interior space at least partially defined by the outer wall, and a vessel bottom surface, wherein the vessel bottom surface comprises a vessel bottom hole disposed through the vessel bottom surface and a vessel bottom rim protruding from the vessel bottom surface and at least partially surrounding the vessel bottom hole; a filter plate disposed in the filter vessel on the vessel bottom surface, the filter plate comprising: a first plate face and a second plate face with a plate body spanning therebetween; a first plate hole disposed through the plate body spanning between the first plate face and the second plate face, wherein the first plate hole is in fluid communication with the vessel bottom hole; and a plate hole rim protruding from the first plate surface and at least partially surrounding the first plate hole, wherein the vessel bottom rim engages with the filter plate to control a position of the filter plate; and a first filter disposed on the first plate face, wherein the first filter engages with the plate hole rim such that the plate hole rim positions the first filter in a desired position.

**13.** The reactor system of claim 12, wherein the filter plate comprises a filter plate recess into the plate body through the second plate face, wherein a shape of the filter plate recess is complementary to a shape of the vessel bottom rim, wherein the vessel bottom rim is disposed in the filter plate recess.

**14.** The reactor system of claim 12, wherein the first filter comprises a filter bore spanning at least partially between a filter first end and a filter second end of the first filter, the filter first end being opposite the filter second end, wherein the filter bore is in fluid communication with the first plate hole and the vessel bottom hole.

**15.** The reactor system of claim 14, wherein the filter system further comprises: a plurality of filters, including the first filter, disposed in the filter vessel; and a baffle plate disposed on the filter second end, wherein the baffle plate facilitates the fluid passing through a portion of the plurality of filters more proximate the outer wall of the filter vessel, wherein the baffle plate comprises a baffle plate hole disposed through the baffle plate facilitating a portion of the fluid to flow between at least two of the plurality of filters.

**16.** The reactor system of claim 15, wherein the outer wall of the filter vessel comprises at least one protrusion extending from the outer wall into the interior space of the filter vessel between at least two of the plurality of filters.

**17.** A reactor system, comprising: a reaction chamber; and a filter system in fluid communication with the reaction chamber, the filter system comprising: a filter vessel comprising an outer wall at least partially defining an interior space; a filter plate disposed in the filter vessel, the filter plate comprising: a first plate face and a second plate face with a plate body spanning therebetween; a first plate hole disposed through the plate body spanning between the first plate face and the second plate face; and a plate hole rim protruding from the first plate surface and at least partially

surrounding the first plate hole; and a plurality of filters disposed on the first plate face, wherein a first filter of the plurality of filters engages with the plate hole rim such that the plate hole rim positions the first filter in a desired position, wherein the outer wall of the filter vessel comprises at least one protrusion extending from the outer wall into the interior space of the filter vessel between at least two of the plurality of filters.

**18.** The reactor system of claim 17, wherein the first filter comprises a filter bore disposed through a filter first end and spanning at least partially between the filter first end and a filter second end, the filter first end being opposite the filter second end, wherein the filter bore is in fluid communication with the first plate hole.

**19.** The reactor system of claim 18, wherein the filter system further comprises a baffle plate disposed on the filter second end, wherein the baffle plate facilitates the fluid passing through a portion of the plurality of filters more proximate the outer wall of the filter vessel.

**20.** The reactor system of claim 19, wherein the baffle plate comprises a baffle plate hole disposed through the baffle plate facilitating a portion of the fluid to flow through the baffle plate, between at least two of the plurality of filters, and through a portion of the plurality of filters more proximate a center of the interior space of the filter vessel.

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